Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

- 1-7. (Canceled)
- 8. (Currently Amended) A component of semiconductor processing equipment, said the component comprising a liquid crystalline polymer on an outer surface thereof, wherein the component is a chamber liner made entirely of the liquid crystalline polymer and/or a component other than a chamber liner.
- 9. (Original) The component according to Claim 8, wherein the liquid crystalline polymer comprises a coating on a surface of a substrate.
- 10. (Original) The component according to Claim 9, wherein the substrate comprises aluminum or an aluminum alloy.
- 11. (Original) The component according to Claim 9, wherein the substrate comprises alumina.
- (Presently Presented) The component according to Claim 10,
 wherein the substrate includes an anodized surface.

13. (Currently Amended) The component according to Claim 9, wherein the liquid crystalline polymer comprises a plasma sprayed coating.

A component of semiconductor processing equipment, the component comprising a substrate including a surface and a plasma-sprayed liquid crystalline polymer coating on the surface.

- 14. (Currently Amended) The component according to Claim 8, wherein the component is a plasma chamber wall, a chamber liner, a gas distribution plate, a gas ring, a pedestal, an electrostatic chuck and/or a focus ring.
- 15. (Original) The component according to Claim 8, wherein the liquid crystalline polymer comprises a preformed sheet covering a surface of a substrate.
- 16. (Currently Amended) The component according to Claim 13, wherein the component comprises a roughened surface that has been subjected to a surface roughening treatment and is in contact with the plasma sprayed coating applied on the roughened surface.
- 17. (Original) The component according to Claim 8, wherein the liquid crystalline polymer contains a filler.

18. (Original) A plasma chamber comprising at least one component according to Claim 8.

19-23. (Canceled)

- 24. (New) The component according to Claim 13, wherein the component is a plasma chamber wall, a chamber liner, a gas distribution plate, a gas ring, a pedestal, an electrostatic chuck and/or a focus ring.
- 25. (New) The component according to Claim 9, wherein the surface of the substrate is a bead or grit-blasted roughened surface which is mechanically keyed or interlocked with the coating.
- 26. (New) The component according to Claim 9, further comprising at least one intermediate layer between the surface of the substrate and the coating.
- 27. (New) The component according to Claim 9, wherein the substrate is of stainless steel, a refractory metal or a polymeric material.
- 28. (New) The component according to Claim 9, wherein the substrate is of a ceramic material selected from the group consisting of silicon carbide, silicon nitride, boron carbide and boron nitride.

- 29. (New) The component according to Claim 13, wherein the surface of the component is a bead or grit-blasted roughened surface which is mechanically keyed or interlocked with the plasma sprayed coating applied on the roughened surface.
- 30. (New) The component according to Claim 13, further comprising at least one intermediate layer between the surface of the component and the plasma sprayed coating.
- 31. (New) The component according to Claim 13, wherein the substrate is of stainless steel, a refractory metal or a polymeric material.
- 32. (New) The component according to Claim 13, wherein the substrate is of a ceramic material selected from the group consisting of silicon carbide, silicon nitride, boron carbide and boron nitride.